

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

▪ In re Divisional **Patent** Application of)
Koichiro TANAKA) Attn: Applications
Based on Serial No. 10/170,739) Branch
Filed: June 14, 2002)
For: LASER IRRADIATION STAGE, LASER IRRADIATION) Date: February 3, 2004
OPTICAL SYSTEM, LASER IRRADIATION APPARATUS, LASER)
IRRADIATION METHOD, AND METHOD OF MANUFACTURING)
A SEMICONDUCTOR DEVICE)

INFORMATION DISCLOSURE STATEMENT

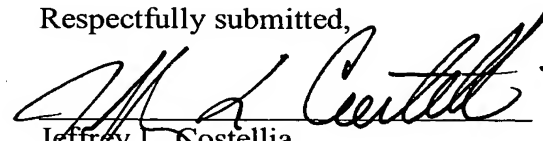
Commissioner for Patents
Alexandria, Virginia 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56 and 37 C.F.R. 1.97-1.99, it is requested that the reference(s) listed on the attached Form PTO-1449 be made of record in the above-identified application. These references were cited in parent application Serial No. 10/170,739 upon which priority is claimed under 35 U.S.C. 120. As a result, copies of the references are not provided.

Japanese Patent Laid-Open Publication No.: 07-130652 corresponds to U.S. Patent No.: 5,643,826.

Respectfully submitted,


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JLC/

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PTO/SB/08A (08-00)

Approved for use through 10/31/2002. OMB 0651-0031

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Substitute for form 1449A/PTO				Complete if Known	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(use as many sheets as necessary)</i>				Application Number	Not Yet Assigned
				Filing Date	February 3, 2004
				First Named Inventor	Koichiro TANAKA
				Group Art Unit	Not Yet Assigned
				Examiner Name	Not Yet Assigned
Sheet	1	of	1	Attorney Docket Number	740756-2709

U.S. PATENT DOCUMENTS						
Examiner Initials*	Cited No.	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code ² (if known)			
		5,643,826		Ohtani et al	07/01/1997	
		6,246,524	B1	Tanaka	06/12/2001	
		6,137,633		Tanaka	10/24/2000	
		6,176,926	B1	Tanaka	01/23/2001	
		6,104,535		Tanaka	08/15/2000	
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		6,176,926		Tanaka	01/23/2001	
		6,077,731		Yamazaki et al.	6/20/2000	

FOREIGN PATENT DOCUMENTS								
Examiner Initials*	Cited No.	Foreign Patent Document			Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶
		Office ³	Number ⁴	Kind Code ⁵ (if known)				
		JP	07-130652	A		05/19/1995		Abstract

Examiner Signature		Date Considered	
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Unique citation designation number. ² See attached Kinds of U.S. Patent Documents. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document.

⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶ Applicant is to place a check mark here if English language Translation is attached.

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